Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

 (Currently amended) A Hafnium-based high-density metallic glass alloy having the ratio of elements of the formula Hf_eCu_bNi_eAl_dY_e wherein;

Y comprises [at-least] one element from Group IVA, IVB, VA, or VB;

- a is less than 45 atomic percent;
- b is from about 15 to about 35 atomic percent;
- c is from about 5 to about 25 atomic percent;
- d is from about 0 to about 20 atomic percent; and
- e is from about 0 to about 15 atomic percent, wherein a+b+c+d+e=100.
- (Previously presented) The metallic glass alloy of claim 1, wherein a is 44.5 atomic percent or less.
- 3. (Previously presented) The metallic glass alloy of claim 2, wherein Y is Ti or Nb.
- (Previously presented) The metallic glass alloy of claim 1, further comprising a density greater than about 7 g/cm3.
- (Previously presented) The metallic glass alloy of claim 4, wherein the density is about 10.5 g/cm3.
- (Previously presented) The metallic glass alloy of claim 1, wherein the alloy exhibits a distinct glass transition temperature, that is at least 0.59 of the liquidus temperature of the alloy.

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- (Previously presented) The metallic glass alloy of claim 1, wherein the ratio of Cu
 to Ni is 2:1
- (Previously presented) The metallic glass alloy of claim 3, wherein the ratio of Cu to Ni is 2:1.
- (Previously presented) The metallic glass alloy of claim 3, having about 5 or more atomic percent Ti.
- (Previously presented) The metallic glass alloy of claim 3, having about 5 or more atomic percent Nb.
- 11. (Previously presented) The metallic glass alloy of claim 1, wherein d is about 10 or more.
- (Previously presented) The metallic glass alloy of claim 1, wherein 35<a<45, 0.15<a>d<20 and 0.15<a>f
- 13. (Previously presented) An article comprising the metallic glass alloy of claim 1.
- 14. (Previously presented) The article of claim 13 having a thickness of at least 1 millimeter in its smallest dimension.
- (Previously presented) The article of claim 13 having a thickness at least 3 millimeters in its smallest dimension.
- (Previously presented) A Hafnium-based high-density metallic glass alloy composition comprising:
- 44.5 atomic percent hafnium;

about 27 atomic percent copper;

about 13.5 atomic percent nickel; about 10 atomic percent aluminum; and about 5 atomic percent titanium or niobium.

- (Previously presented) The composition of claim 16 having a density greater than 7 g/cm3.
- (Previously presented) The composition of claim 16, having a density of about 10.9 g/cm3 or more.
- (Previously presented) The composition of claim 16, wherein the composition exhibits a distinct glass transition temperature of at least 0.59 of the liquidus temperature of the composition.
- 20. (Previously presented) An article comprising the metallic glass alloy of claim 16.
- (Previously presented) The article of claim 20 having a thickness of at least 1
 millimeter in its smallest dimension
- (Previously presented) The article of claim 20 having a thickness of at least 3
 millimeters in its smallest dimension.
- (Previously presented) The article of claim 20, wherein the ratio of copper to nickel is 2:1.
- (Previously presented) The article of claim 20, wherein the metallic glass is at least partially amorphous.
- (Previously presented) The article of claim 20, wherein the article has an elastic strain to failure between about 1.8 and 2.2 percent elongation.

- (Previously presented) The article of claim 20, wherein the object has a quasistatic compressive yield stress of between about 1.8 and 2.2 GPa.
- (Previously presented) The article of claim 20, wherein the object has a dynamic high-strain-rate yield stress of between about 1.3 and 1.6 GPa.
- (Previously presented) A metallic glass alloy comprising Hf, Cu, and Ni in eutectic combination with Al, Ti, Nb or a combination thereof, having a density greater than about 7 g/cm3.
- (Previously presented) A method for forming a Hafnium-based high-density metallic glass alloy comprising:

combining 44.5 atomic percent hafnium;

about 27 atomic percent copper;

about 13.5 atomic percent nickel;

about 10 atomic percent aluminum; and

about 5 atomic percent titanium or niobium.

- (Previously presented) The metallic glass alloy of claim 1, wherein the alloy is formed by electric arc melting.
- (Previously presented) The metallic glass alloy of claim 1, wherein the alloy is formed by induction melting.
- (Previously presented) The article of claim 16, wherein the article is formed by vacuum suction casting.

- (Previously presented) The article of claim 16, wherein the article is formed by permanent mold casting, injection die easting, pour easting, planar flow easting, melt spinning, or extrusion.
- 34. (Previously presented) A method for making an Hafnium-based high-density alloy generally represented by the formula H₂Cu₂Ni₂Al₂V₂, wherein Y includes at least one element selected from Group IV or Group V transition metal elements, wherein Hf is not equal to Y, Group VA, VIII, IVB, or VB, wherein a +b+e+d+e=100% (atomic netreent), and a is less than 45 in an invariant combination.
- (Previously presented) An alloy according to Claim 34 invariantly combining Hf,
 Cu, and Ni with Al, and Ti or Nb to form a metallic glass alloy having a density greater than about 7 g/cm3.
- 36. (Previously presented) The alloy of Claim 35 wherein the alloy contains Al.
- 37. (Previously presented) The alloy of Claim 36 wherein the alloy contains Ti or Nb.
- (Previously presented) The alloy of Claim 35 wherein the alloy contains an element from Group IVA or Group IVB.
- (Previously presented) The alloy of Claim 36 wherein the alloy contains an element from Group IVA or Group IVB.
- (Previously presented) The alloy of Claim 34 wherein preferably 35<a<45, 15<b<35, 5<e<25, 0<d<20, and 0<e<15.

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